

REMARKS

Applicants request favorable consideration and allowance of the subject application in view of the preceding amendments and the following remarks.

Claims 1, 3-6, 15 and 16 are presented for consideration. Claims 1 and 15 are independent. Claim 16 has been added to recite additional features of the subject invention. Support for this claim can be found in the application as originally filed. Therefore, no new matter has been added.

Claim 1 and 3-6 were previously allowed in this application. Applicants submit that these claims, as well as claim 15 and new claim 16, patentably define features of the near-field photomask and the near-field exposure apparatus of the present invention. Accordingly, the instant application should be in condition for allowance. Favorable consideration and an early Notice of Allowance are requested.

Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should continue to be directed to our below-listed address.

Respectfully submitted,

A handwritten signature in black ink, appearing to read "Steven E. Warner", is written over a horizontal line.

Attorney for Applicants
Steven E. Warner
Registration No. 33,326

FITZPATRICK, CELLA, HARPER & SCINTO
30 Rockefeller Plaza
New York, New York 10112-3801
Facsimile: (212) 218-2200

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